

2.1. LABORATORY X-RAY SCATTERING

Table 2.1.5

Comparison of divergence and intensity for several types of germanium channel-cut monochromators

In each case, the monochromator is coupled with a graded multilayer providing 3×10^9 counts per second at $<0.028^\circ$ beam divergence. The values in parentheses denote the percentage of intensity diffracted by the respective monochromator crystals.

Type	(<i>hkl</i>)	Divergence ($^\circ$)	Intensity
Two-bounce	220, symmetric	<0.0052	5.0×10^7 (~1.5%)
Two-bounce	220, asymmetric	<0.0085	3.3×10^8 (~10%)
Two-bounce	400, asymmetric	<0.0045	4.8×10^7 (~1.5%)
Four-bounce	220, symmetric	<0.0035	6.5×10^6 (~0.2%)
Four-bounce	220, asymmetric	<0.0080	2.7×10^7 (~1%)
Four-bounce	440, symmetric	<0.0015	2.2×10^5 (~0.075%)

germanium channel-cut monochromators are compared in terms of divergence and intensity.

Switching between different channel-cut monochromators is extremely easy these days and can be accomplished without the need for any tools and without realignment. This is also true for cases where a beam offset is introduced, *e.g.* by switching between two- and four-bounce channel-cut monochromators. In sophisticated instruments such an offset can be compensated fully automatically by a software-controlled motor.

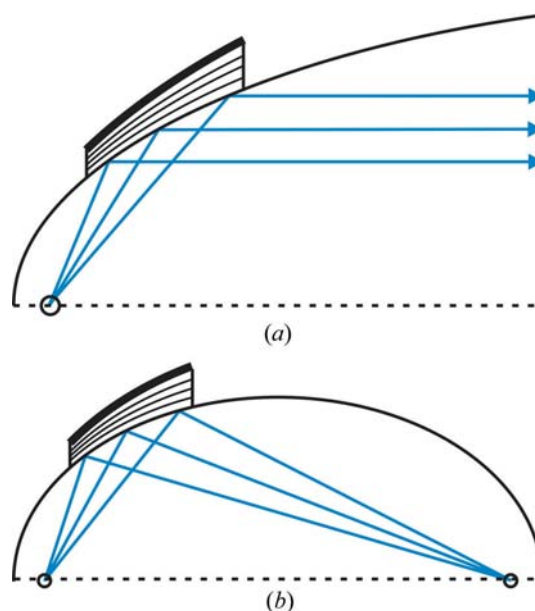
The combination of different types of channel-cut monochromators in both the incident and diffracted beam allows the construction of advanced diffractometer configurations with extremely high resolution capabilities. It should be emphasized that laboratory X-ray diffractometers can have identical optical configurations to diffractometers operated at synchrotron beamlines. The important and obvious difference, however, is the extremely low flux coming from laboratory X-ray sources, which is further diminished by each reflection in a channel-cut monochromator (Table 2.1.5). While such configurations work perfectly for strongly scattering single-crystal layers in thin films, for example, analysis of ideal powders is normally not possible.

2.1.6.3.3. Reflective X-ray optics

2.1.6.3.3.1. Multilayer mirrors

Multilayer mirrors used in laboratory X-ray diffractometers are efficient beam conditioners, using total reflection as well as Bragg reflection on inner interfaces of a multilayer structure to modify beam divergence, cross-section size, shape and – to some extent – spectral bandwidth. A comprehensive description of current mirror designs and important mirror properties is found in the VDI/VDE Guideline 5575 Part 4 (2011).

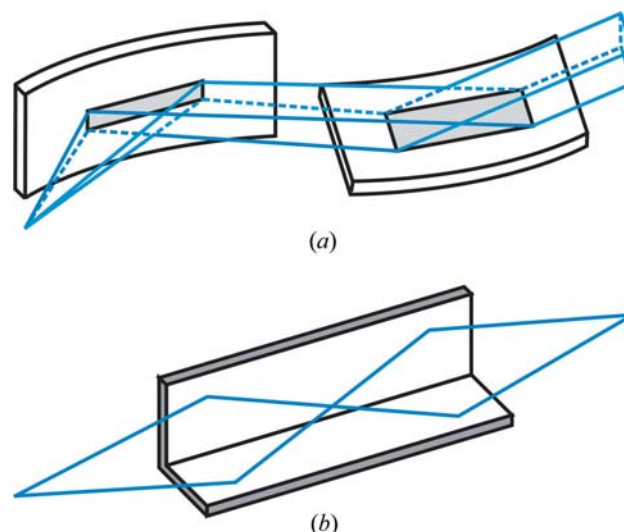
Multilayer mirrors consist of a multilayer coating deposited on a flat or curved substrate. The *imaging* characteristics are mostly determined by the contour of the mirror surface as defined by the substrate surface. The most common contours include planes, ellipsoids, paraboloids, elliptic cylinders or parabolic cylinders. The *spectral reflection* properties are determined by the coating, which may consist of some 10 up to 1000 alternating layers of amorphous low-density ('spacer') and high-density ('reflector') materials, with a period of a few nanometres. The first curved mirrors were produced by depositing the multilayers on a flat substrate that was subsequently bent to the desired contour, yielding typical r.m.s. slope errors of about 15 arcsec. By using prefigured substrates with r.m.s. slope errors below 1.7 arcsec, significantly improved reflectivity and lower beam divergence are obtained. Laterally graded multilayer mirrors (so-called 'Göbel mirrors') have a layer thickness gradient parallel to the surface

**Figure 2.1.19**

Schematic of graded multilayer mirrors. (a) Parabolic mirror for parallelization of a divergent beam, or, if reversed, focusing of a parallel beam. In the latter case the mirror will also filter some specimen fluorescence. (b) Elliptical mirror for focusing of a divergent beam.

(Schuster & Göbel, 1996), which, when combined with a planar, parabolic or elliptic substrate contour, produce a divergent, parallel or focusing beam. Fig. 2.1.19 illustrates graded multilayer mirrors for parallelization and focusing in the plane of diffraction.

For beam conditioning in two perpendicular directions, two perpendicularly oriented curved mirrors may be used, as illustrated in Fig. 2.1.20. In the Kirkpatrick–Baez scheme (Kirkpatrick & Baez, 1948), two mirrors are cross-coupled as shown in Fig. 2.1.20(a). This setup has some issues related to the inherently different capture angles and magnification of both mirrors, resulting in less flux from smaller sources and in different divergences in both directions for elliptical mirrors. The Montel optics (Montel, 1957) shown in Fig. 2.1.20(b) overcome these issues by arranging both mirrors in a 'side-by-side' configuration.

**Figure 2.1.20**

Examples for orthogonally positioned curved mirrors for beam conditioning. (a) Kirkpatrick–Baez scheme employing two parabolic mirrors to create a parallel beam, (b) Montel optics employing two elliptical mirrors side-by-side to create a focusing beam.